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INFORMATION DISCLOSURE STATEMENT		Applicant Wang	
		Filing Date July 7, 2003	Group

U.S. PATENT DOCUMENTS							
*Examiner Initials	Document Number	Issue Date	Name	Class	Subclass	Filing Date if Appropriate	

FOREIGN PATENT DOCUMENTS								
*Examiner Initials	Document Number	Publication Date	Country	Class	Subclass	Translation		
						Yes	No	
JZ	880 303 B1	11/25/98	EPO					
↓	989 778 A1	03/29/00	EPO					
	WO 90/13148	11/01/90	PCT					
	WO 00/70406	11/23/00	PCT					
	WO 01/04938 A1	01/18/01	PCT					
	WO 01/39288 A1	05/31/01	PCT					

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)		
JZ		"Pattern Transfer: Self-Assembled Monolayers as Ultrathin Resists", Xia et al., Microelectronic Engineering 32, 1996, pp. 255-268
↓		"Unconventional Methods for Fabricating and Patterning Nanostructures", Xia et al., Chem. Rev. 99, 1999, pp. 1823-1848
		"Selective Deposition in Layer-by-Layer Assembly: Functional Graft Copolymers as Molecular Templates", Jiang et al., Langmuir 16, 2000, pp. 8501-8509
		"Trapping Light in Polymer Photodiodes with Soft Embossed Gratings", Roman et al., Advanced Materials, 12, No. 3, 2000, pp. 189-195
		"Patterning of Polymer Light-Emitting Diodes with Soft Lithography", Granlund et al., Advanced Materials, 12, No. 4, 2000, pp. 269-273
		"Submicrometer Patterning of Charge in Thin-Film Electrets", Jacobs et al., Science Vol. 291, March 2, 2001, pp. 1763-1766
		"Printing Meets Lithography: Soft Approaches to High-Resolution Printing", Michel et al., IBM J. Res. & Dev. Vol. 45, No. 5, September 2001, pp. 697-719
		"Pedot Surface Energy Pattern Controls Fluorescent Polymer Deposition by Dewetting", Wang et al., Thin Solid Films 449, 2004, pp. 125-132
↓		International Search Report in PCT/GB03/02917 dated September 8, 2004
		Search Report in GB 0215858.2 dated February 25, 2003

Examiner /Joshua Zimmerman/	Date Considered 11/11/2006
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